

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L4	1566	(sputter with etch\$4) same clean\$4	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/05 13:01
L5	166	(chamber or reactor) same (polymer or by-products) same sputter	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/05 13:01
L6	12823	(chamber or reactor) same (wall or internal) same (polymers or residues)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/05 13:05
L8	4687	(chamber or reactor) same (wall or internal) same (polymers or residues) same (clean\$4 or remov\$4)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/05 13:38
L9	1144	8 and etch\$4	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/05 13:40
L10	472	9 and (ar or argon)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/05 13:06
L11	4795	(chamber or reactor) with (wall or internal) with (polymers or residues)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/05 13:38
L12	694	11 and etch\$4 and clean\$4	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/05 14:19
L19	12	stamper-anthony-kendall.in.	USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/04/05 14:16
L20	2	"6776851".pn.	USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/05 14:16